IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Taku HIRAYAMA et al.

Mail Stop: PCT

Serial No. NEW

Attorney Docket No. 2005_0892A

Filed June 1, 2005

CHEMICAL-AMPLIFICATION TYPE SILICON-BASED POSITIVE-WORKING PHOTORESIST COMPOSITION [Corresponding to PCT/JP2003/015344 Filed December 1, 2003]

PRELIMINARY AMENDMENT

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

In the interest of compact prosecution, please amend the present application as follows: